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The 10th International Conference

Charged & Neutral Particles Channeling Phenomena

8-13 September 2024 Riccione (Rimini), Italy

Implementing Capillary Design for Reliable VHEE Beam Delivery

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10th International Conference, Charged & Neutral Particles Channeling Phenomena September 8-13, 2024, Riccione (Rimini), Italy

Outline

2

- Ø Very High Energy Electron (VHEE) for Radiotherapy
- Ø Laser-plasma Acceleration (LPA) for VHEE
- \triangleright Introducing I-LUCE Facility
- Ø Plasma Module & Plasma Diagnostic
- \triangleright Plasma Modelling in COMSOL Multiphysics

VHEE: For RT

3

Several Electron Beam Energies (all in MeV)

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A. Lagzda et al., VHEE Beams, 2020

INF Istituto Nazionale di Fisica Nuclear

HLUCE

VHEE: Toward Experimental Implementation via LPAs

VHEE can be generated using LPAs, which leverage plasma technology and intense laser pulses to propel charged particles to very high energies over short distances (via gas jets or discharge capillaries).

4

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LPAs: Laser Wakefield Acceleration (LWFA)

LWFA Mechanism

Ø Laser Pulse Injection: A powerful laser pulse is directed into a plasma.

\triangleright Creation of Plasma Wake:

5

The high-intensity laser pulse generates a strong electric field in the plasma, known as the plasma wake.

Ø Electron Displacement:

This electric field from the laser pulse pushes electrons away from their original positions in the plasma.

Ø Formation of Positive Charge Region:

This movement of electrons creates a region of positive charge because the heavier ions remain relatively stationary while the lighter electrons move away.

Ø Electron Acceleration:

Electrons are accelerated as they ride the wake created by laser and gain energy as they move through these waves.

Principal Acceleration Diagram

Electron Acceleration

T. Tajima, J. Dowson, Phys. Rev. Lett, 43 (1979)

Laser Electron Accelerator

T. Tajima and J. M. Dawson Department of Physics, University of California, Los Angeles, California 90024 (Received 9 March 1979)

An intense electromagnetic pulse can create a weak of plasma oscillations through the action of the nonlinear ponderomotive force. Electrons trapped in the wake can be accelerated to high energy. Existing glass lasers of power density 10^{18} W/cm² shone on plasmas of densities 10¹⁸ cm⁻³ can yield gigaelectronvolts of electron energy per centimeter of acceleration distance. This acceleration mechanism is demonstrated through computer simulation. Applications to accelerators and pulsers are examined.

W.P. Leemans et al., Phys. Rev. Lett, 113 (2014)

Acceleration Scheme: Laser Wakefield Acceleration (LWFA)

E [GV/m 1 ≈ 96 (n_e [cm⁻³])^{1/2}

 $E_0 = \frac{cm_e\omega_p}{g}$, $n_e = 2 \times 10^{17}$ cm⁻³ \Rightarrow $\boxed{E_0 \approx 40 \text{ GV/m}}$

Plasma wavelength:

$\lambda_p \equiv \frac{2\pi c}{\omega_c} \approx 100 \,\mu \text{m}$ $T_{pulse} \approx \frac{\lambda_p}{2\pi c} \approx 50 \,\text{fs}$

Plasma frequency:

 $\omega_p = \sqrt{\frac{n_e e^2}{m_e \varepsilon_0}}$

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Accelerating field:

Dependency on Plasma Wavelength:

Wave Amplitude and Laser Pulse Length:

 \triangleright Longer pulses generally excite larger wakefields.

 \triangleright The maximum accelerating field that can be achieved is influenced by the plasma wavelength (λ_n) , which is related to the plasma density (n_e) .

pulse) depends on the length (vety short) and intensity of the laser pulse.

Dependency on Plasma Density:

6

- \triangleright A higher plasma density results in a shorter plasma wavelength.
- \triangleright Higher plasma density leads to stronger collective effects, enhancing the wakefield amplitude and the accelerating field.
- \triangleright Higher density plasmas support stronger wakefields, leading to more efficient acceleration

Regulation by Background Plasma Density:

- \triangleright The background plasma density effectively regulates the accelerating field.
- \triangleright The density determines the plasma wavelength, which affects the strength of the wakefield and the efficiency of electron acceleration.

«Plasma density controls the strength of the accelerating field»

I-LUCE at INFN-LNS (Laboratori Nazionali del Sud)

7

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I-LUCE Facility: Plasma Source (Plasma-discharge Capillary)

A capillary is a small, narrow tube, often made of dielectric materials such as quartz, non-commercial plastic (VeroClear), sapphire, glass, or etc. that confines the plasma.

9

I-LUCE Facility: Plasma LAB (Direct Current Plasma Discharge)

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Plasma Diagnostic: Density Measurements

- Emission Spectroscopy: Studies the light emitted by atoms, etc. during transitions from higher to lower energy states.
- 12 • Broadening Mechanism: Natural, Doppler, and Collisional (Stark) broadenings, that can allow us to measure the electron density.

Plasma Diagnostic: Temperature Measurements

13 Intensity Ratios: Using the intensity ratios of different spectral lines to infer the electron temperature.

S. S. Harilal et al., 52, 3 (1998)

S. Arjmand et al., JINST, 18, P08003 (2023)

HR Griem, Academic Press Inc, App. III (1974)

14 Plasma Density: 10^{17} cm^{-3} Temperature: 1 - 4 eV

Two mechanisms:

- > Ablation: Typically generated by intense laser pulse focused on solid target (in our case small amount of surface ablation), causing material to be ejected/melted from the surface.
- Ø Desorption: Refers to when atoms or molecules leave the surface of material without fully vaporizing the surface (the most dominant mechanism.

VeroClear $(C_5O_2H_8)$: 82.92% Carbon 16.50% Oxvgen 0.57% Nitrogen due to impurity (78% in the air) \sim Emitted

OI, OII, OIII, NI, NII, NIII, CI, CII, CIII

Considerd

 \cdot O II (471.9803 nm) or N II (471.8377 nm) • O III (508.8922 nm) or N III (454.970 nm)

Emitted Spectral Lines Considered Spectral Lines

Plasma Diagnostic: Temperature Measurements

Plasma Diagnostic: Temperature Simulation (O & N Ions)

VeroClear $(C_5O_2H_8)$: 82.92% Carbon 16.50% Oxygen 0.57% Nitrogen due to impurity

NIST Databa[se \(https://physics.nist.gov/PhysRefData/ASD/levels_form.htm](https://physics.nist.gov/PhysRefData/ASD/levels_form.html)l)

Nitrogen II Nitrogen III

Saha/LTE Spectrum for mixture C:82.92%+N:0.57999999999999933%+O:16.50% $T_a = 2.32$ eV, N_a = 6.8e+17 cm⁻³, Resolution = 1000. Total of 365 lines; lon abundances are given in

Wavelength (nm)

Saha/LTE Spectrum for mixture C:82.92%+N:0.5799999999999983%+O:16.50% T_e = 2.34 eV, N_e = 6.8e+17 cm⁻³, Resolution = 1000. Total of 365 lines; lon abundances are given in

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18 B. Radjenovic et al., Acta Physica Slovaca 63(3):105-205

Plasma Diagnostic: 2D Discharge Modelling in COMSOL Multiphysics

Paschen curve for different gases in electrical discharge

COMSOL
MULTIPHYSICS

Particle-particle reaction (excitations, ionisations, chrage exchange) Reactions (ionisations, recombinations) on cathode and capillary surface.

Ar collision processes Ar: Atom, Ar*: Excited Argon, Ar+: Ionized Argon

1) $e + Ar \Rightarrow e + Ar^*$ (Elastic Scattering) 2) $e + Ar \Rightarrow e + Ar^* \Rightarrow e + Ar + photon (Excitation)$ 3) $e + Ar^* => e + Ar$ (Superelastic) 4) $e + Ar \Rightarrow 2e + Ar + (Ionization)$ 5) $e + Ar^* \Rightarrow 2e + Ar^*$ (lonization) 6) $Ar^* + Ar^* = > e + Ar + Ar +$ (Penning Ionization) 7) Ar* + Ar => Ar + Ar (Metastable Quenching)

Surface Reactions:

Ar atoms or metastable atoms intercat with the wall and transition back to ground state

1) $Ar+ \Rightarrow Ar$

2) $Ar^* = > Ar$ https://www.comsol.com/

 \triangleright A capillary of length L = 3 cm and diameter of d = 1 and 2 mm, filled with Argon at the pressure $p = 7.5$ Torr (10) mbar) is considered, to generate a plasma in the range of 10^{17} cm⁻³.

- \triangleright From the Argon Paschen curve, the minimum voltage required to initiate gas breakdown results V0 ~ 800 V for a capillary of length $L = 3$ cm, at the pressure $p = 7.5$ Torr (10 mbar) .
- \triangleright At voltage lower than the one needed to initiate the breakdown, no discharge occurs (the electron density is lower than the initial one, fixed at $n_{ei} = 10^7$ cm⁻³).
- \triangleright When the applied voltage is higher than the breakdown one, the electron density starts to increase.
- \triangleright All values taken in the simulation time $t = 2 \mu s$, at which the density results almost stationary.

https://www.comsol.com/

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Electron Density Vs Applied Voltage

19

 $\widehat{\mathsf{E}}_{0.028}$

 ∞

0.028

0.026

0.024

0.022

 0.02

0.018

 0.016

 0.014

 0.012

 0.01

0.008

0.006

 0.004

 0.002

r

m

Longitudinal axis of the capillary (L = 3 cm)

Longitudinal axis of the capillary (L

3cm/long-2mm/diameter 10 mbar, 10 kV, 2 μs With Argon gas

PRILIMINARY

Plasma Stability: Shot-to-shot Stability

 161

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Plasma Stability: Stabilization by a Laser Technique

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I-LUCE Facility: Electron Beam Expectation

Normalized Charge

Normalized Charge

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